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APPLICATION NO.	FI	ILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/695,591	10/28/2003		Paul Jayachandran Joseph	62020-1560	5369
24504	7590	08/24/2005		EXAMINER	
		N, HORSTEMEY	CULBERT, ROBERTS P		
100 GALLE STE 1750	RIA PAR	KWAY, NW	ART UNIT	PAPER NUMBER	
ATLANTA,	GA 303	39-5948		1763	

DATE MAILED: 08/24/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
	10/695,591	JOSEPH ET AL.				
Office Action Summary	Examiner	Art Unit				
The MAN INC DATE of the committee of the	Roberts Culbert	1763				
The MAILING DATE of this communication a Period for Reply	appears on the cover sheet wi	In the correspondence address				
A SHORTENED STATUTORY PERIOD FOR REI THE MAILING DATE OF THIS COMMUNICATIO Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication. If the period for reply specified above is less than thirty (30) days, a If NO period for reply is specified above, the maximum statutory peri Failure to reply within the set or extended period for reply will, by sta Any reply received by the Office later than three months after the may earned patent term adjustment. See 37 CFR 1.704(b).	N. R. 1.136(a). In no event, however, may a re- reply within the statutory minimum of thirt- iod will apply and will expire SIX (6) MON- atute, cause the application to become AB.	eply be timely filed y (30) days will be considered timely. THS from the mailing date of this communication. ANDONED (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on 25	<u>5 July 2005</u> .					
2a) This action is FINAL . 2b) ⊠ T	his action is non-final.					
·	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims						
4) ☐ Claim(s) 1-24 is/are pending in the applicating 4a) Of the above claim(s) 1-17 is/are withdrating 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 18-24 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and	awn from consideration.	· · · · · · · · · · · · · · · · · · ·				
Application Papers						
 9) The specification is objected to by the Exam 10) The drawing(s) filed on <u>28 October 2003</u> is/a Applicant may not request that any objection to the Replacement drawing sheet(s) including the corr 11) The oath or declaration is objected to by the 	are: a)⊠ accepted or b)⊡ ot he drawing(s) be held in abeyan rection is required if the drawing(ce. See 37 CFR 1.85(a). s) is objected to. See 37 CFR 1.121(d).				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documed 2. Certified copies of the priority documed 3. Copies of the certified copies of the priority documed application from the International Bured * See the attached detailed Office action for a life to the priority documed application from the International Bured * See the attached detailed Office action for a life to the priority documed application from the International Bured * See the attached detailed Office action for a life to the priority documed application from the International Bured * See the attached detailed Office action for a life to the priority documed application from the International Bured * See the attached detailed Office action for a life to the priority documed application from the International Bured * See the attached detailed Office action for a life to the priority documed application from the International Bured * See the attached detailed Office action for a life to the priority documed application from the International Bured * See the attached detailed Office action for a life to the priority documed application from the International Bured * See the attached detailed Office action for a life to the priority documed application from the International Bured * See the attached detailed Office action for a life to the priority documed application from the International Bured * See the attached detailed Office action for a life to the priority documed application from the International Bured * See the attached detailed Office action for a life to the priority documed application from the International Bured * See the attached detailed Office action for a life to the priority documed application from the International Bured * See the attached detailed Office action for a life to the priority documed application from the International Bured * See the attached detailed Office action for a life to the priority documed application from the Internation for a life to the	ents have been received. ents have been received in Apriority documents have been eau (PCT Rule 17.2(a)).	oplication No received in this National Stage				
Attachment(s)						
) Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948)		ummary (PTO-413))/Mail Date				
Paper No(s)/Mail Date 2/2/04, 2/25/05.		formal Patent Application (PTO-152)				

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DETAILED ACTION

Election/Restrictions

Claims 1-17 withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a nonelected invention, there being no allowable generic or linking claim. Election was made without traverse in the reply filed on 7/25/05.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 18-23 are rejected under 35 U.S.C. 102(b) as being anticipated by U.S. Patent 6,096,656 to Matzke et al.

Regarding Claim 18, Matzke et al. teach a method of fabricating a microstructure comprising: providing a substrate (18) having a sacrificial polymer layer (32) disposed thereon; disposing a framing material (20) onto at least a portion of the sacrificial polymer layer; and disposing an overcoat layer (36) onto the framing material, wherein the framing material substantially separates the sacrificial polymer layer from the overcoat layer.

Regarding Claim 19, Matzke teaches removing the sacrificial layer to define an air-region within the overcoat layer, the framing material engaging at least a portion of the air-region on an inside surface of the framing material and engaging the overcoat layer on an outside surface of the framing material.

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Regarding Claim 20, Matzke et al. teach the overcoat layer is selected from polyimides, polynorbornenes, epoxides, polyarylenes ethers, parylenes, inorganic glasses, and combinations thereof. (Col. 9, Line 60 – Col. 10, Line 2)

Regarding Claim 21, Matzke et al. teach the framing material is selected from SiO2, Si3N4, SiOxNy (where x is from 0.01 to 2 and y is from 0.01 to 1.33), and Al2O. (Col. 8, Lines45-59)

Regarding Claim 22, Matzke et al. teach the sacrificial layer polymer is selected from polyimides, polynorbornenes, epoxides, polyarylenes ethers, polyarylenes, inorganic glasses, and combinations thereof. (Col. 9, Lines 4-8)

Regarding Claim 23, Matzke et al. teach a method for fabricating a microstructure, comprising: providing a structure having a substrate, an overcoat layer, a sacrificial polymer layer in an area within the overcoat layer, and a framing material between at least a portion of the sacrificial polymer layer and the overcoat layer; and removing the sacrificial polymer layer to form an air-region within the area defined by the sacrificial material.

Claims 18-24 are rejected under 35 U.S.C. 102(e) as being anticipated by U.S. Patent 6,599,436 to Matzke et al.

Regarding Claim 18, Matzke et al. teach a method of fabricating a microstructure comprising: providing a substrate (12) having a sacrificial polymer layer (36) disposed thereon; disposing a framing material (38) onto at least a portion of the sacrificial polymer layer; and disposing an overcoat layer (the overcoat layer reads on the silicon dioxide barrier described at Col. 8, Lines 12-16 and/or the additional layer described at Col. 9, Lines 49-52) onto the framing material, wherein the framing material substantially separates the sacrificial polymer layer from the overcoat layer.

Regarding Claim 19, Matzke teaches removing the sacrificial layer (36) to define an air-region within the overcoat layer (Figure 3I), the framing material engaging at least a portion of the air-region on an inside surface of the framing material and engaging the overcoat layer on an outside surface of the framing material.

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Regarding Claim 20, Matzke et al. teach the overcoat layer is selected from polyimides, polynorbornenes, epoxides, polyarylenes ethers, parylenes, inorganic glasses, and combinations thereof.

Regarding Claim 21, Matzke et al. teach the framing material is selected from SiO2, Si3N4,

SiOxNy (where x is from 0.01 to 2 and y is from 0.01 to 1.33), and Al2O. (Col. 8, Line 60 – Col. 9, Line 6)

Regarding Claim 22, Matzke et al. teach the sacrificial layer polymer is selected from polyimides

(Col. 7, Lines 1-5), polynorbornenes, epoxides, polyarylenes ethers, polyarylenes, inorganic glasses, and combinations thereof. (Col

Regarding Claim 23, Matzke et al. teach a method for fabricating a microstructure, comprising: providing a structure having a substrate (12), an overcoat layer (Col. 8, Lines 12-16 and/or Col. 9, Lines 49-52), a sacrificial polymer layer in an area within the overcoat layer, and a framing material (38) between at least a portion of the sacrificial polymer layer and the overcoat layer; and removing the sacrificial polymer layer (36) to form an air-region within the area defined by the sacrificial material.

Regarding Claim 24, Matzke et al. inherently teaches that the polymer sacrificial layer is solvent-incompatible with the overcoat since the solvent in the sacrificial polymer removal step removes only the sacrificial layer. Further, since Matzke et al. suggests widely different materials with respect to solvency (glass, plastic, metal) for the sacrificial layers and overcoat the different materials are clearly "solvent incompatible" as broadly claimed by applicant.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Roberts Culbert whose telephone number is (571) 272-1433. The examiner can normally be reached on Monday-Friday (8:30-5:00).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Parviz Hassanzadeh can be reached on (571) 272-1435. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

R. Culbert

PARVIZ HASSANZADEH SUPERVISORY PATENT EXAM